OUT 3 0 2003 Applica

500.39825X00

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant(s):

T. HIROSE, et al

Serial No.:

09/800,495

Filed:

March 8, 2001

For:

METHOD OF DETECTING AND MEASURING ENDPOINT OF

POLISHING PROCESSING AND ITS APPARATUS AND

METHOD OF MANUFACTURING SEMICONDUCTOR DEVICE

USING THE SAME

Group:

1765

Examiner:

L. Umez Eronini

## **AMENDMENT AFTER FINAL ACTION**

Mail Stop AF Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

October 30, 2003

Sir:

In response to the Office Action July 30, 2003, the following amendments and remarks are respectfully submitted in connection with the above-identified application, as listed below and as set forth on the following pages:

Amendment of the Claims; and

Remarks are included following the amendments.

**BEST AVAILABLE COPY**